

Semiconductor Nanowires: Opportunities & Challenges

Albert Davydov Metallurgy Division

Outline:

- NW research in our Division
- Nano-LEDs case study:
 - Design: Core-shell vs. Axial Heterostructures
 - Growth: VLS vs. VS (nucleation, phase diagrams, defects)
 - Quantum Discs: InGaN phase separation, strain, defects
- Summary

Acknowledgement

Denis Tsvetkov, Sergiy Krylyuk – GaN and Si CVD growth

Kris Bertness (Boulder) – GaN MBE growth

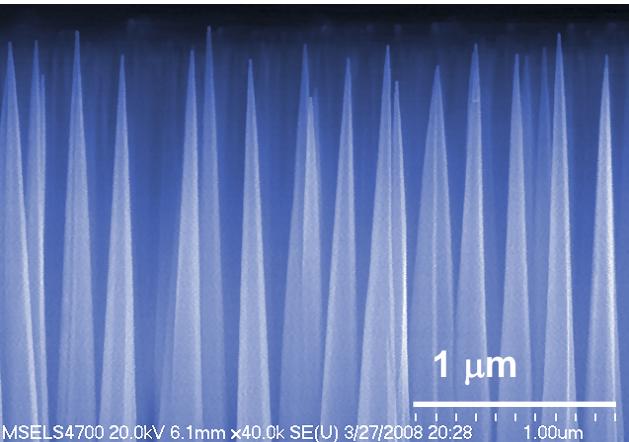
Igor Levin, Vladimir Oleshko – TEM

Abhishek Motayed – nanodevices

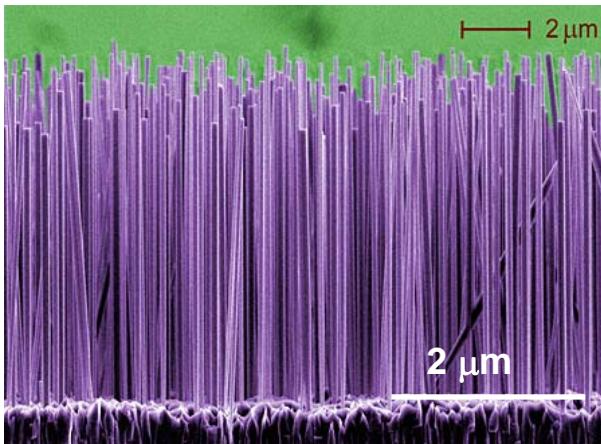
John Schlager, Norman Sanford (Boulder) – opt. spectroscopy

Semiconductor NW Growth at NIST

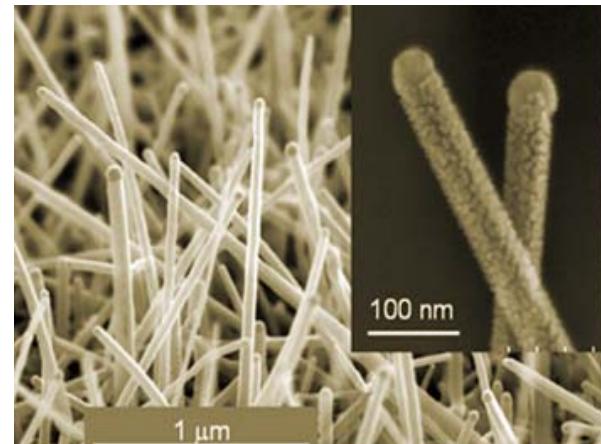
NIST



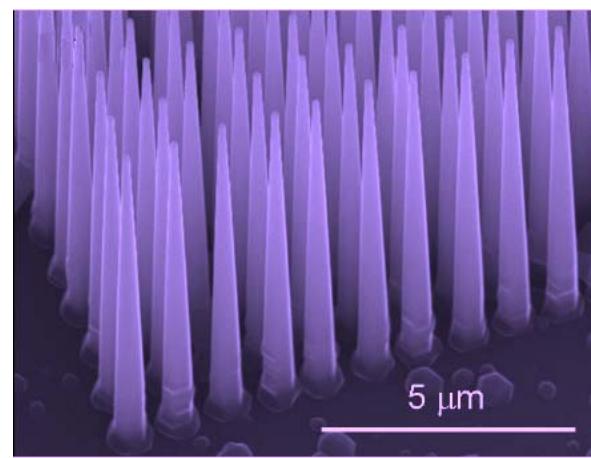
AlN by HVPE (D. Tsvetkov)



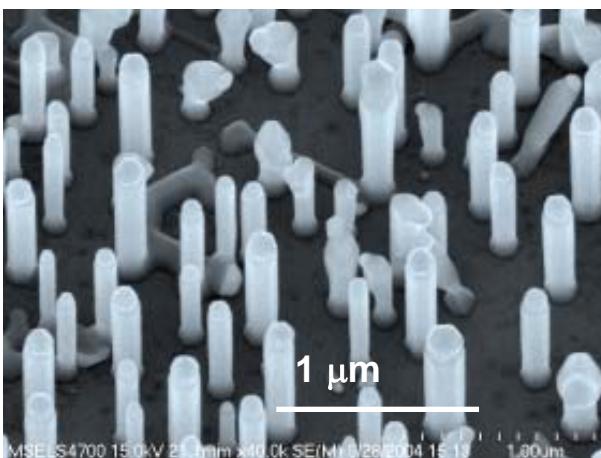
GaN by MBE (K. Bertness)



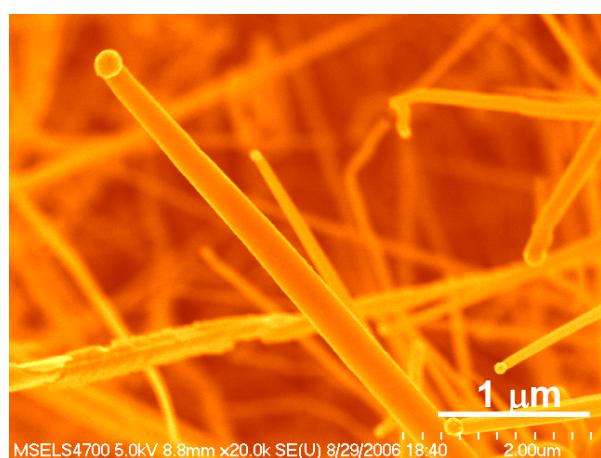
GaN by HVPE (D. Tsvetkov)



Si by CVD (S. Krylyuk)



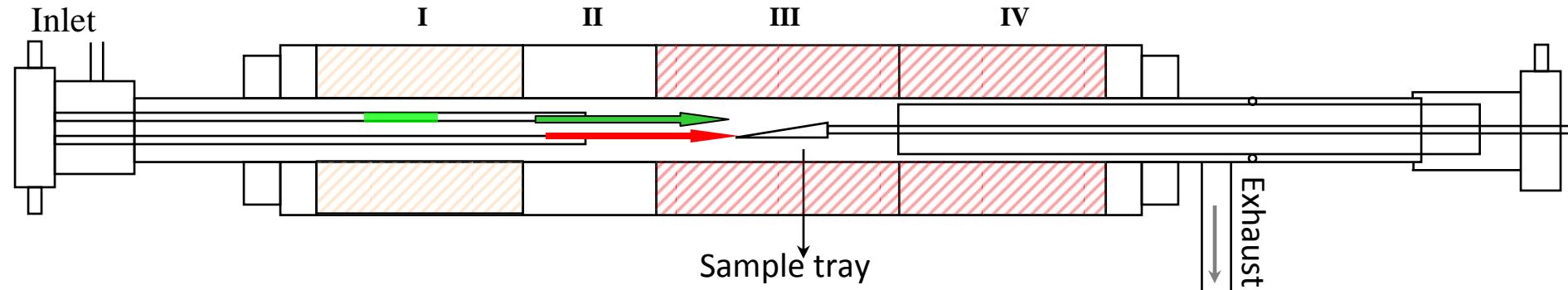
ZnO by CVD (B. Nikoobakht)



SiC by sublimation (S. Sundaresan)

Key Issues:

- uncontrolled NW dimensions, orientation and defects
- lack of metrology: new measurements & models needed

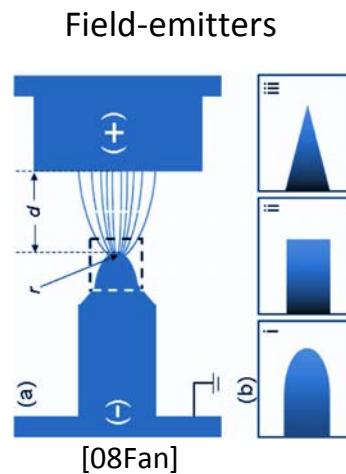
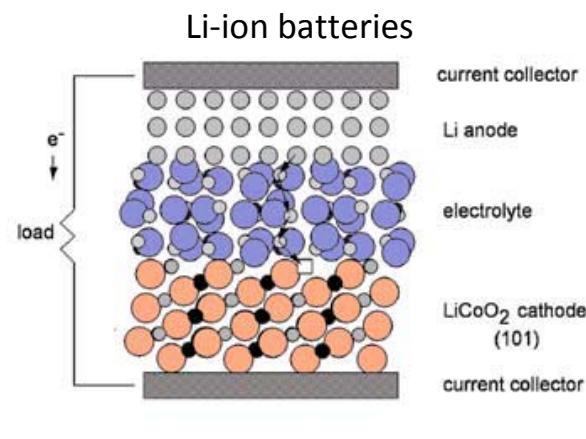
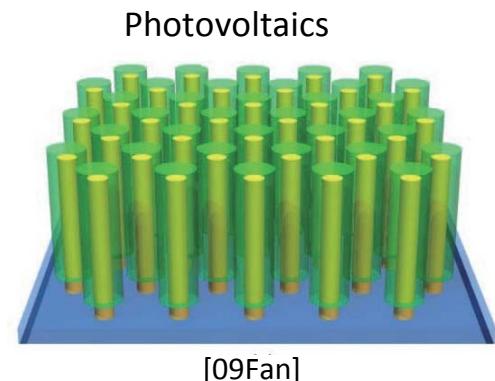
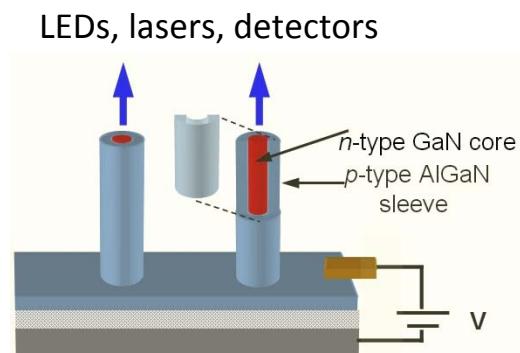
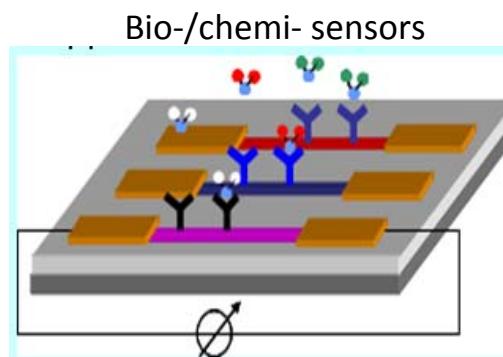


System Features:

- Variable pressure (3 mTorr – 760 Torr)
- Fast growth interruption
- Growth of alloys (AlGaN, InGaN) and heterostructures (GaN/AlN, GaN/AlGaN etc.)
- In situ* n- and p- doping

$T_g = 700^\circ\text{C} - 1050^\circ\text{C}$; $P = 450$ torr;

$t = 20\text{s} - 90\text{ min}$; $V/\text{III} = 20-30$ (VS) & 0.3-1 (VLS)



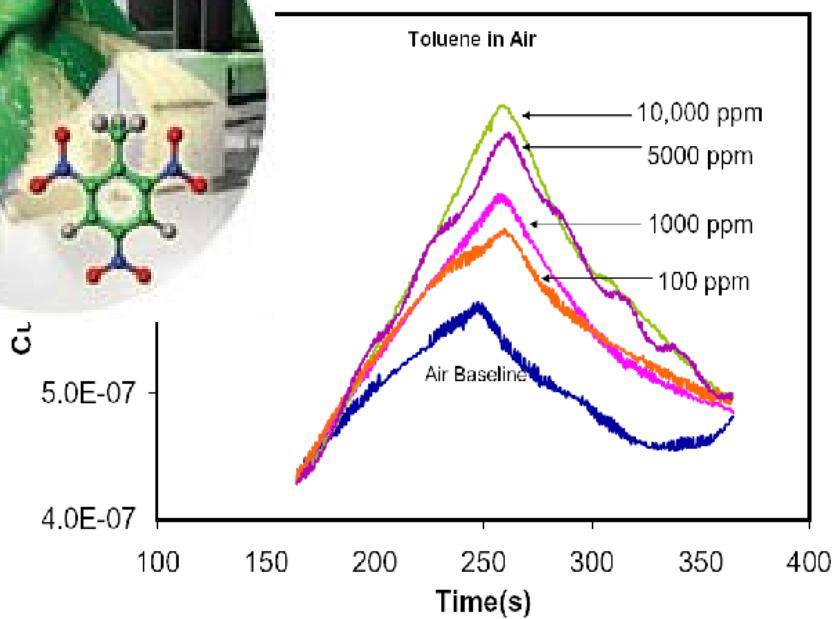
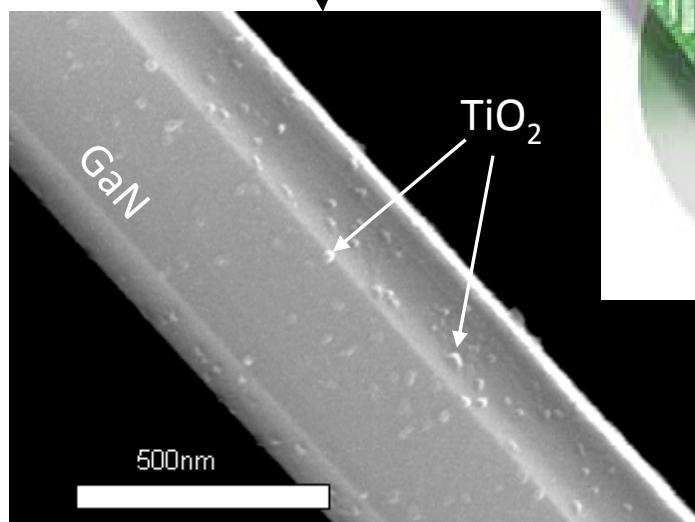
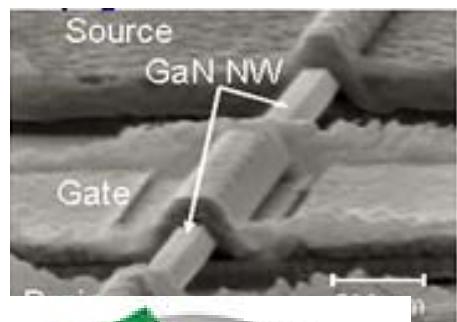
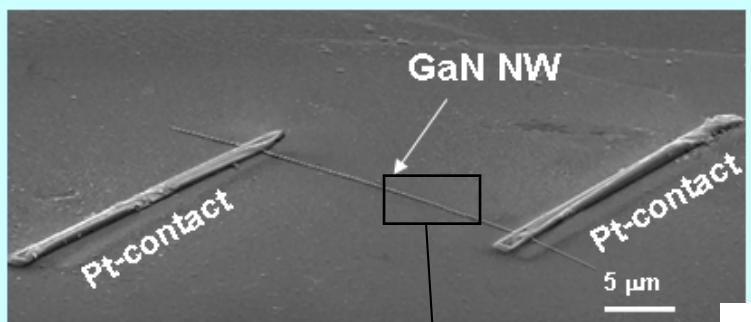
Advantages of NW arrays over thin-film devices:

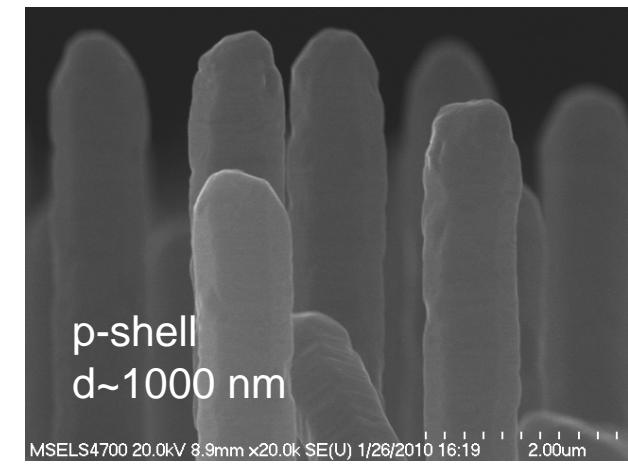
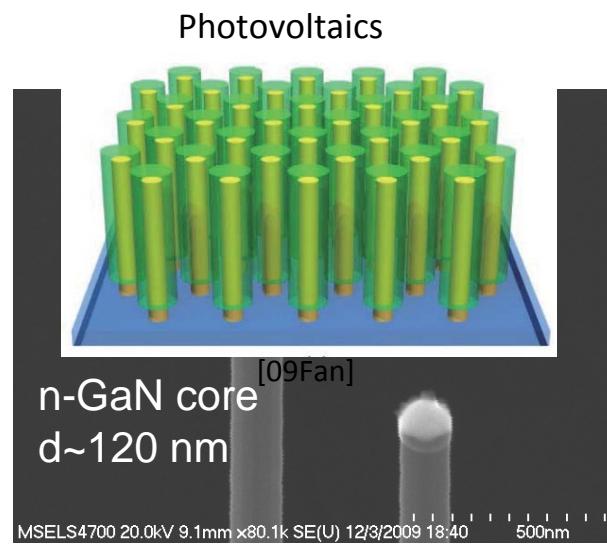
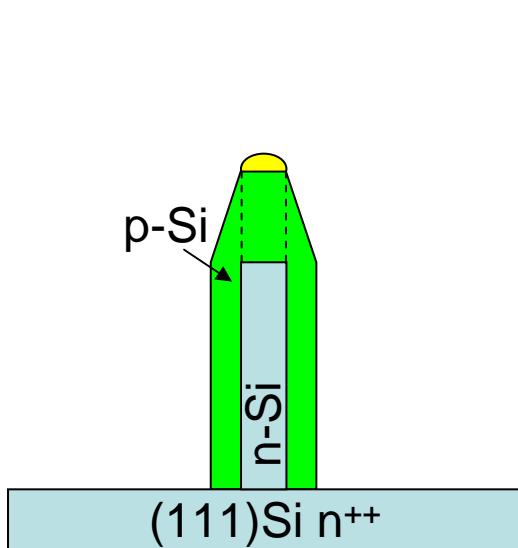
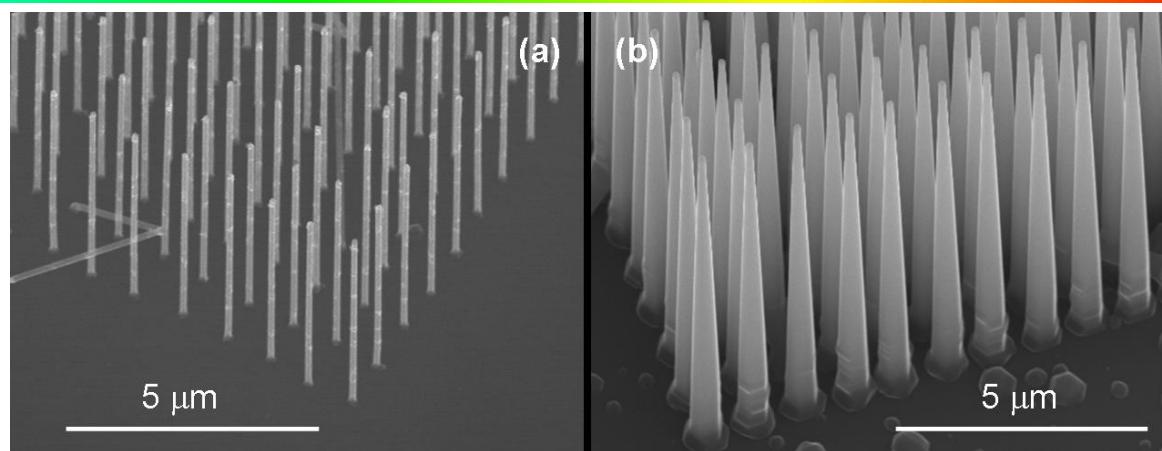
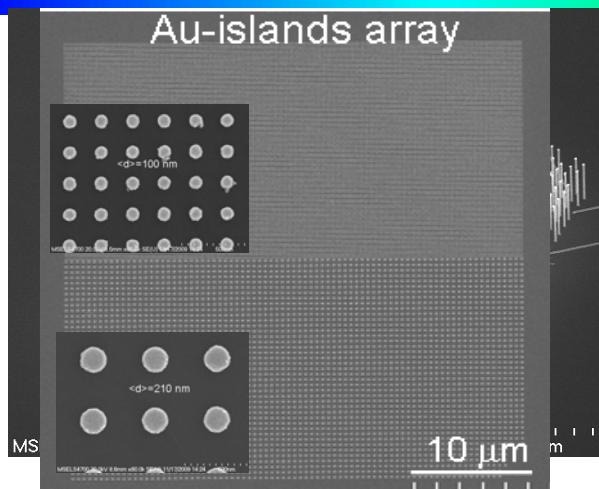
- high efficiency (no defects, high surface/volume ratio)
- high selectivity (multiple materials and/or devices on a single chip)
- new types of devices (quantization effects)

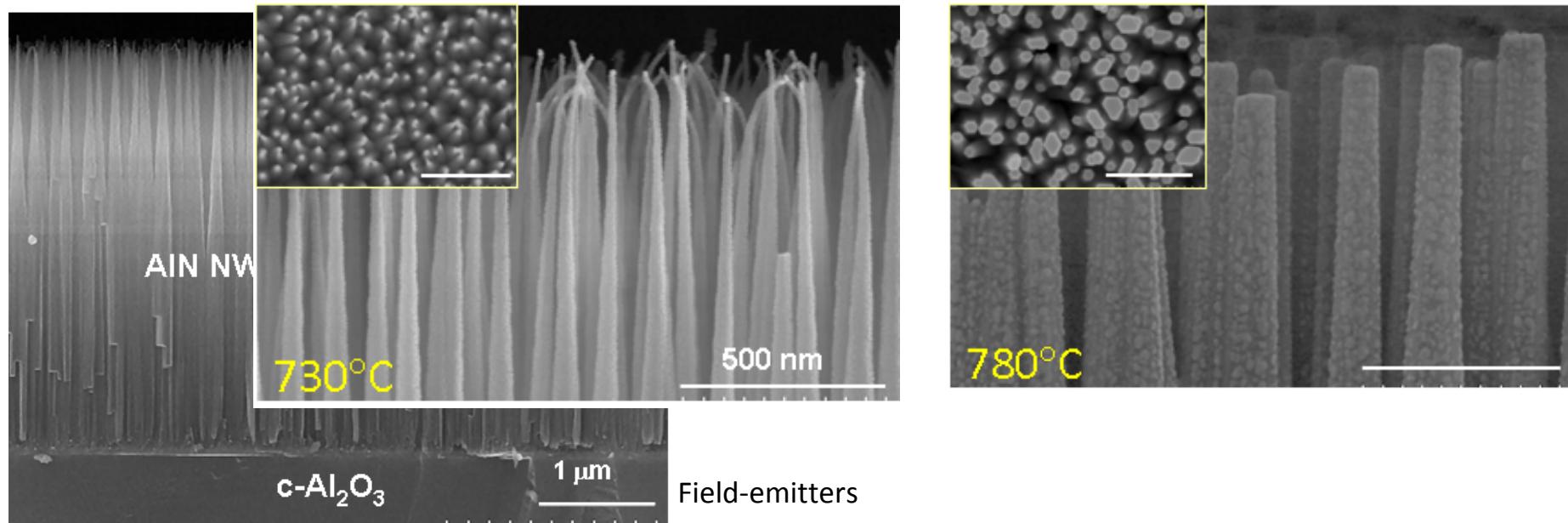
GaN NW Gas Sensors (Chemiresistors)

Abhishek Motayed, Geetha Aluri

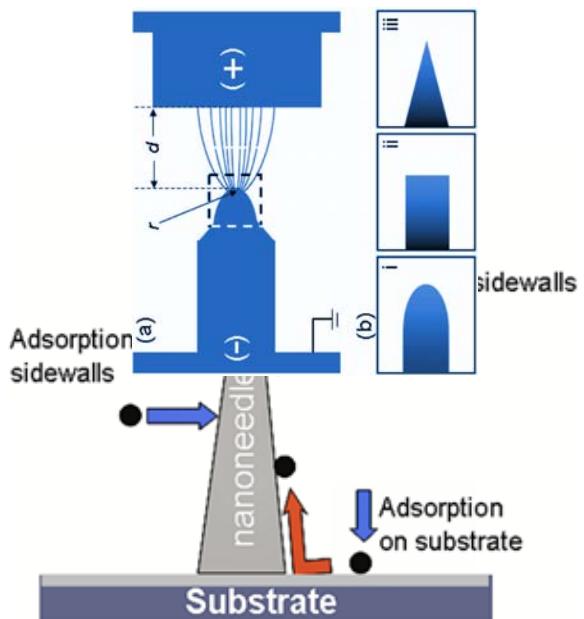
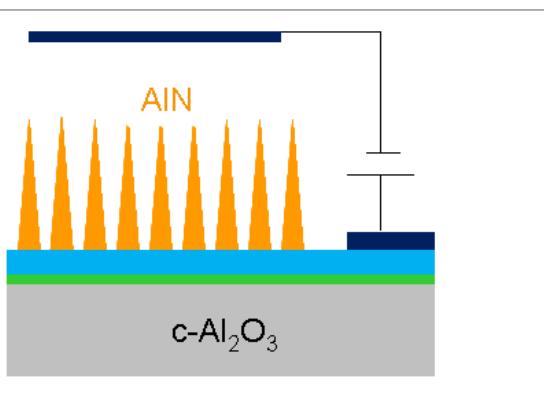
NIST



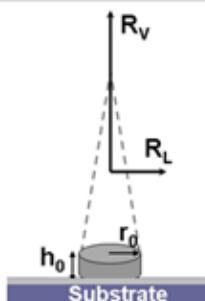




Schematic AlN NW Field-Emitter

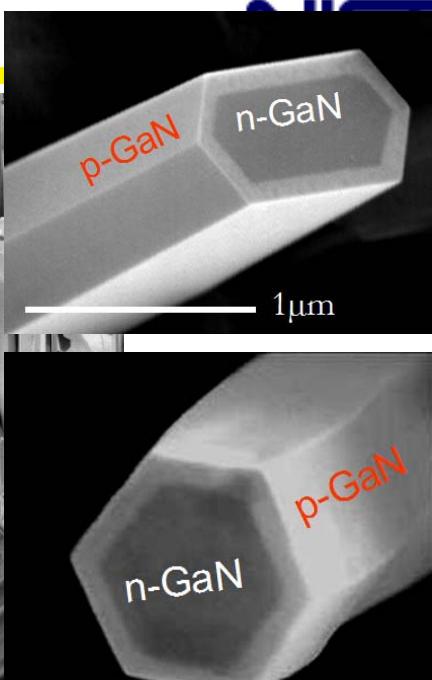
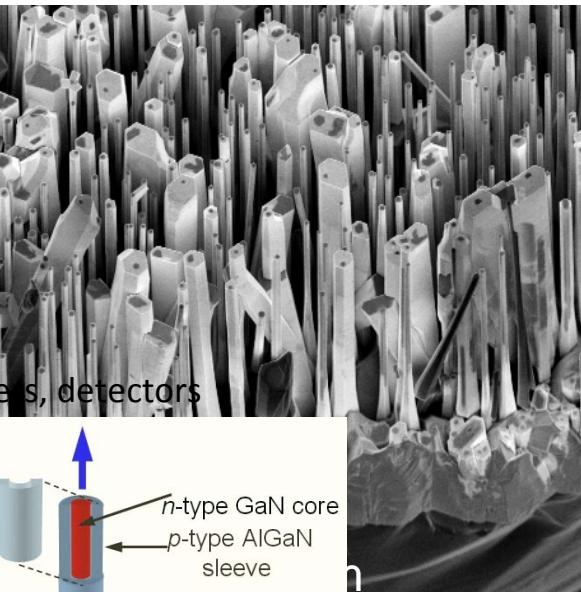
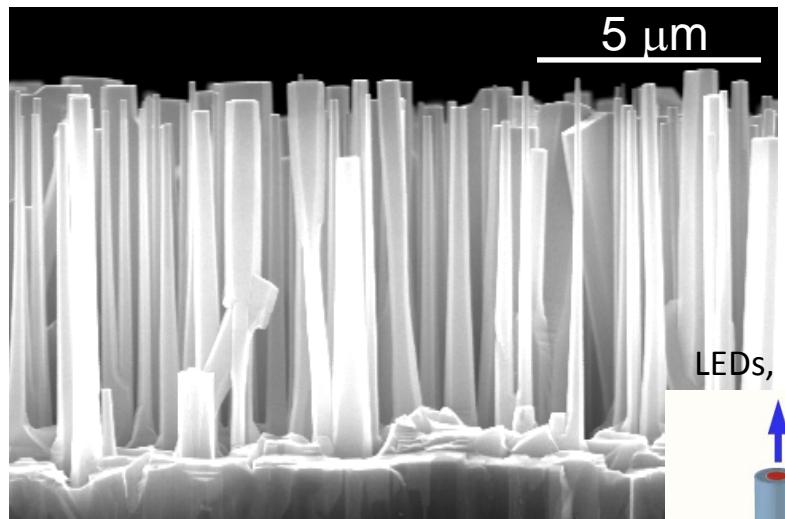


Cone height: $h = h_0 + R_v \cdot t$
 Cone radius: $r = r_0 + R_L \cdot t$
 $h_0 = r_0 \sim 2 \text{ nm}$
 $R_v \sim 200 \text{ nm/min}; R_L \sim 2 \text{ nm/min}$

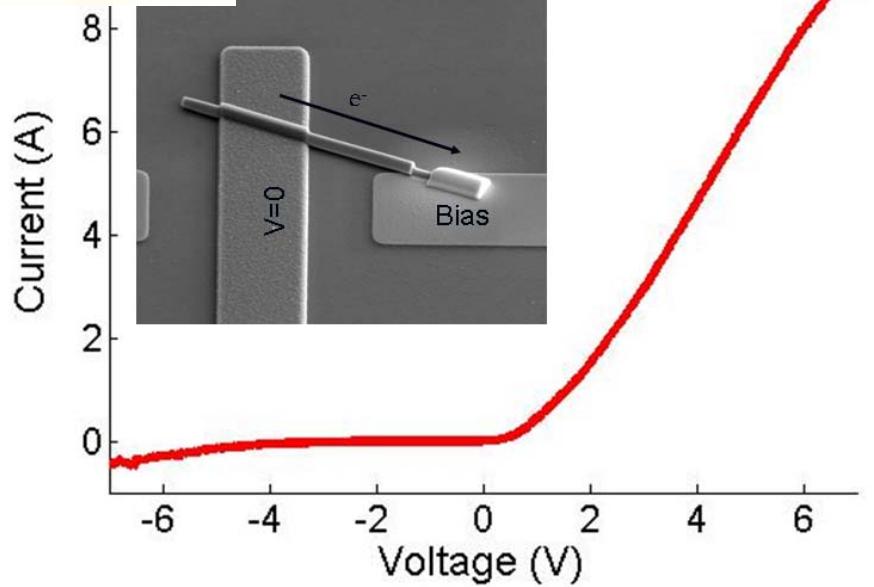
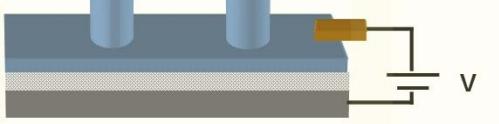
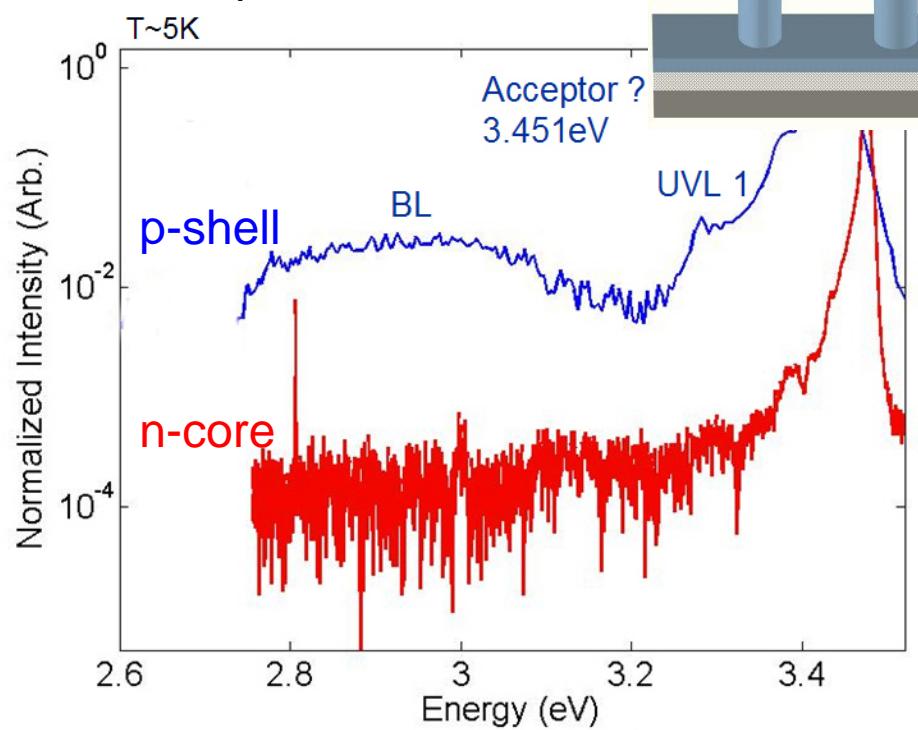


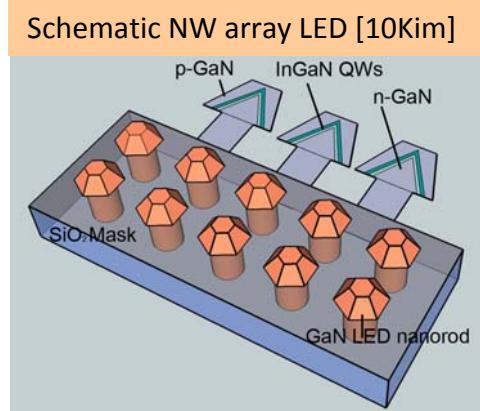
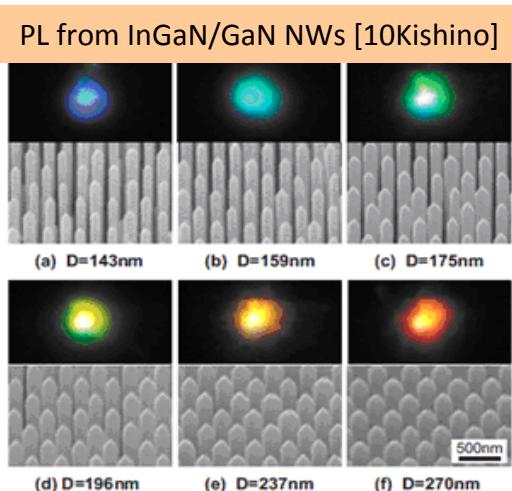
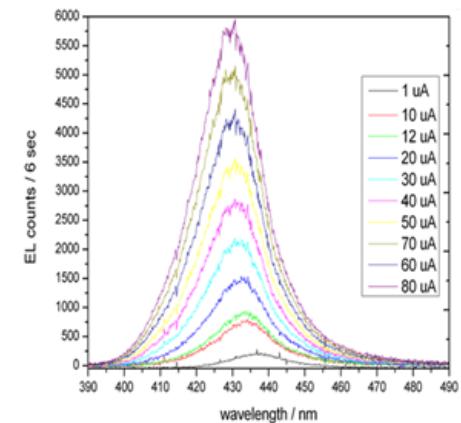
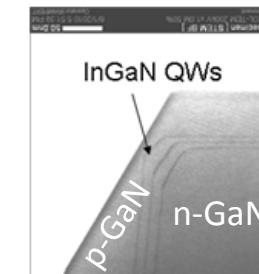
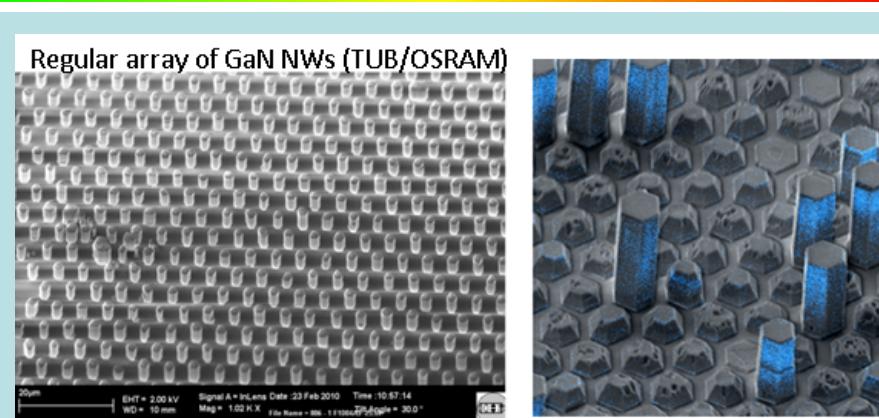
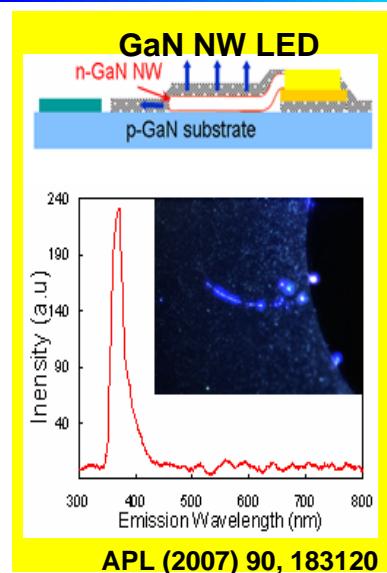
n/p Core-Shell GaN NWs for LEDs

IMS program w/Boulder

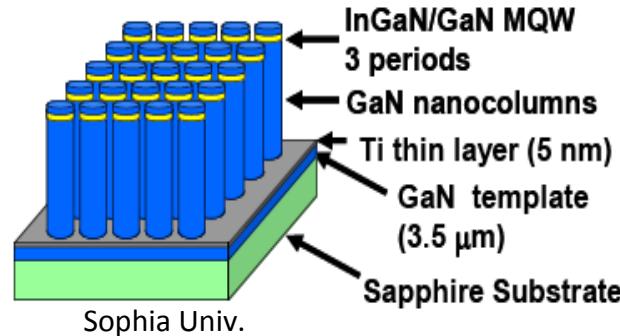
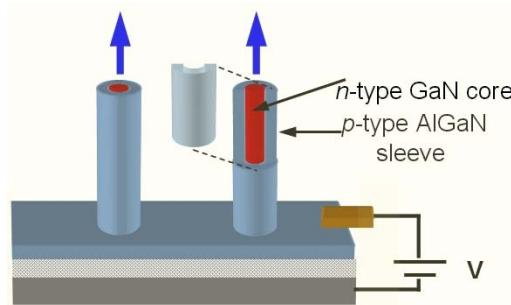


HVPE p-shells over n-core

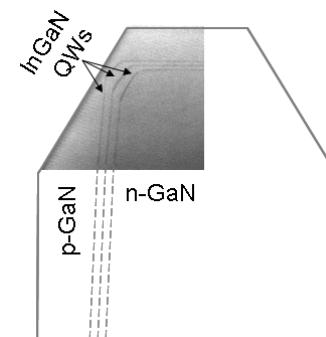




LEDs, lasers, detectors



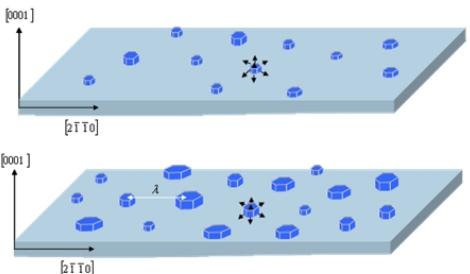
- Design: Core-shell vs. Axial Heterostructures
- Growth: VLS vs. VS
 - phase diagrams; nucleation, defect formation, competition
- Quantum Disks:
 - strain, InGaN phase separation, defects



ISOM

Nucleation of Self-Assembled Nanorods

What determines the average density and diameter?



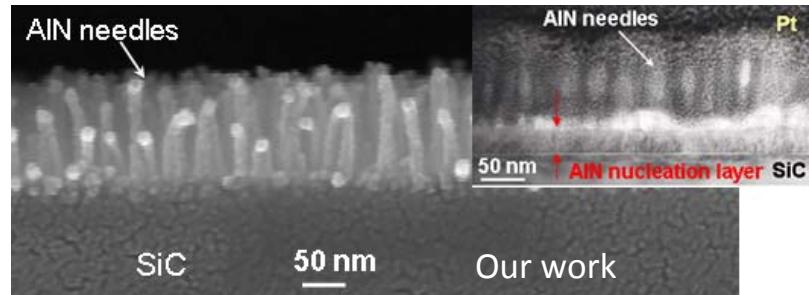
3D islands formation by Volmer-Weber growth. Islands are **stable** above a critical radius.

Islands density saturates when the average distance equals the Ga diffusion length. The process takes time. Different to QDot formation. No wetting layer

$$\lambda = F(T, \text{III/V, substrate})$$

Lateral growth stops when local stoichiometry on the top sides is reached. Then, all Ga adatoms climbing along sidewalls incorporate at the NR top.

15th Molecular Beam Epitaxy Workshop, Zakopane, Poland. March, 2009.
MRS Fall Meeting, Boston MA, USA, November, 2009.



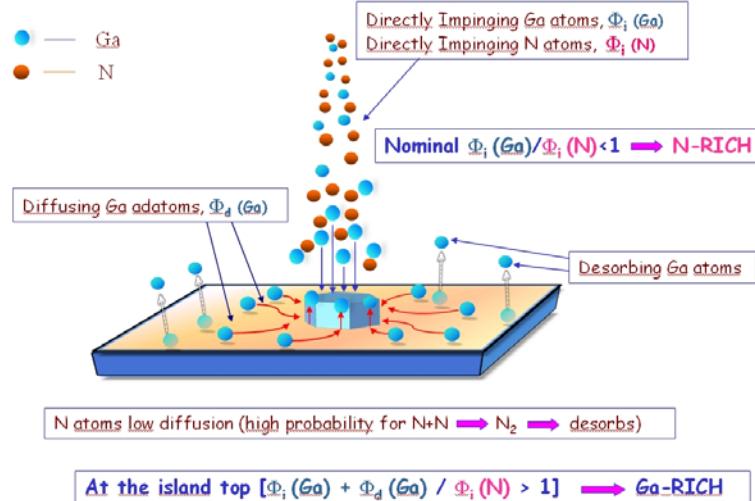
- Spontaneous formation of wetting layer: not understood yet (no modeling)?

Courtesy Enrique Colleja

ISOM

Nanorods Nucleation and Growth

● — Ga
● — N



N atoms low diffusion (high probability for N+N → N₂ → desorbs)

At the island top [$\Phi_i(\text{Ga}) + \Phi_d(\text{Ga}) / \Phi_i(\text{N}) > 1$] → Ga-RICH

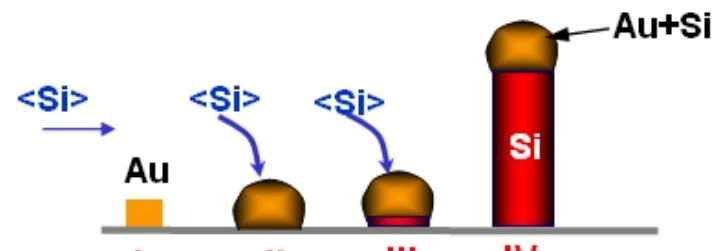
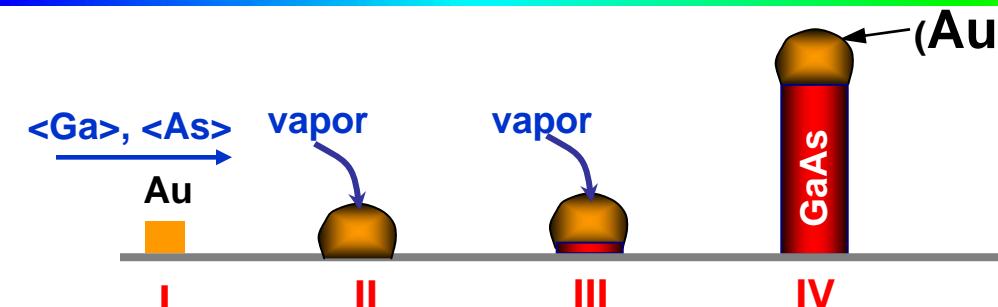
M. Knelangen et al., Nanotechnology 21, 245705 (2010)
V. Consonni et al, Phys. Rev. B81, 085310 (2010)

PHYSICAL REVIEW B 79, 241308(R) (2009)

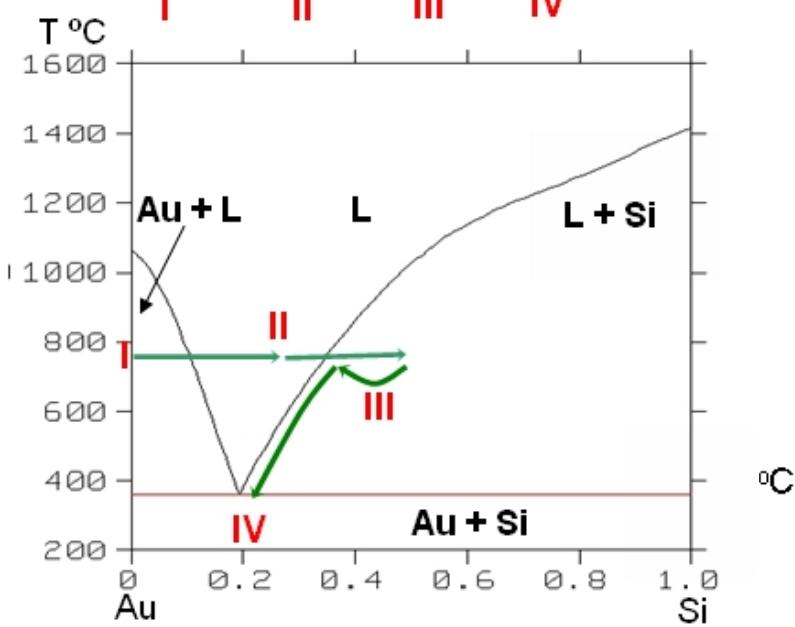
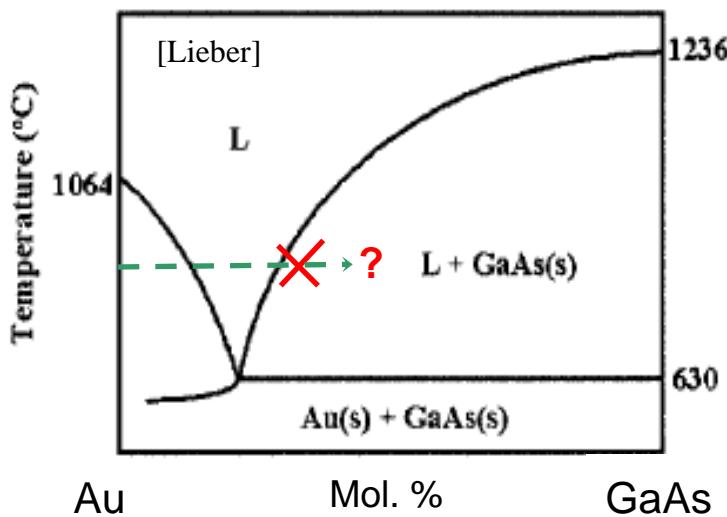


Large anisotropic adatom kinetics on nonpolar GaN surfaces:
Consequences for surface morphologies and nanowire growth

Liverios Lymparakis* and Jörg Neugebauer



Does VLS path lie in the Au-GaAs binary?



- Growth path can not be traced on the Au-GaAs section:

Not possible to:

- define growth temperature or trace compositions
- choose metal for catalyst

Need ternary diagram!

- Thermodynamic description of VLS growth for **compounds** is needed

Effect of VLS and VS Growth on Defects

NIST

Nano Res (2010) 3: 528–536
DOI 10.1007/s12274-010-0013-9
Research Article

Direct Comparison of Catalyst-Free and Catalyst-Induced GaN Nanowires

Caroline Chéze^{1,†}, Lutz Geelhaar^{1,†}, Oliver Brandt¹, Walter M. Weber^{2,†}, Henning Riechert^{1,†}, Steffen Münch³, Ralph Rothmund³, Stephan Reitzenstein³, Alfred Forchel³, Thomas Kehagias⁴, Philomela Komninou⁴, George P. Dimitrakopoulos⁴, and Theodoros Karakostas⁴

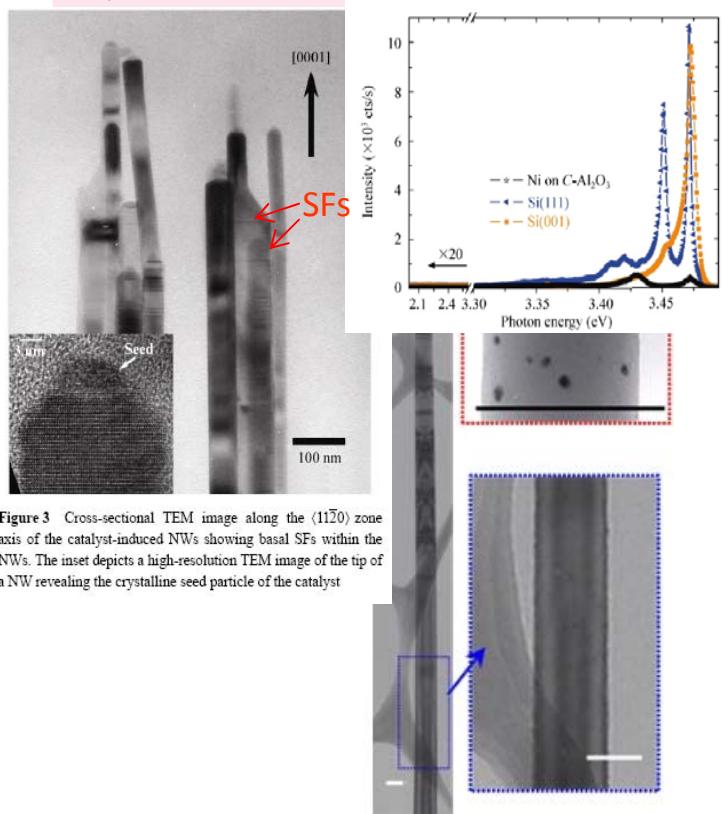
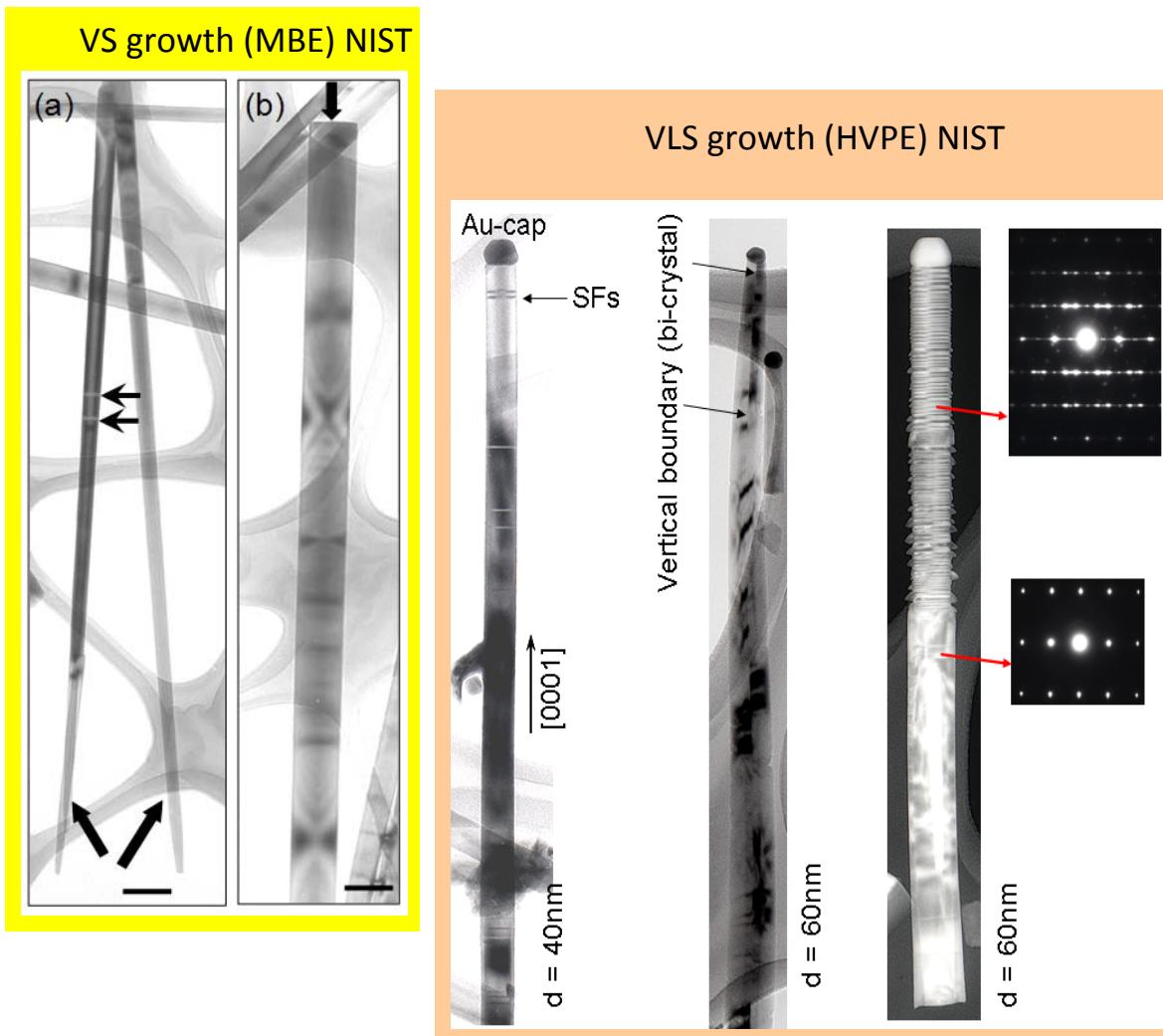
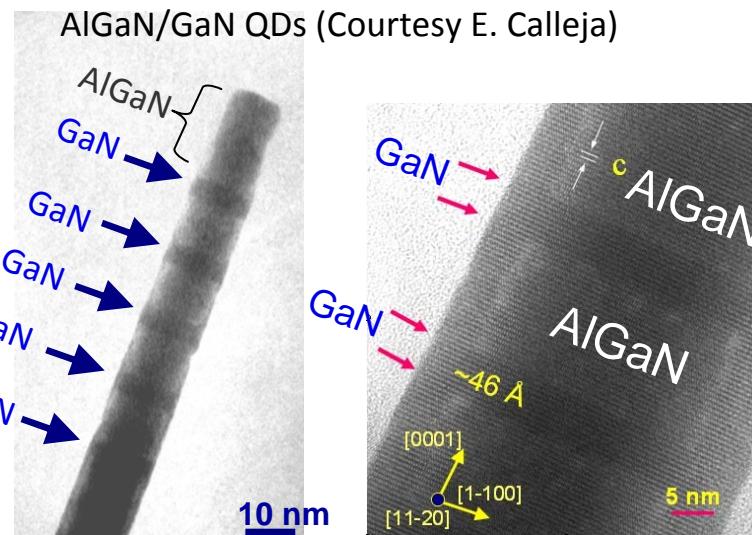
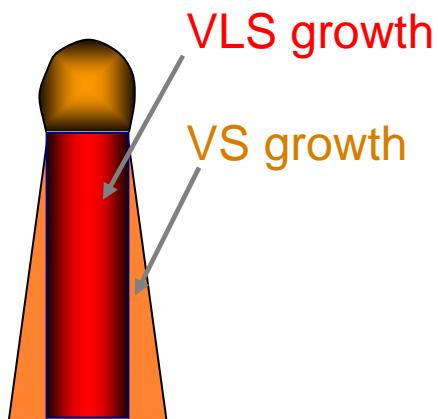


Figure 3 Cross-sectional TEM image along the $\langle 11\bar{2} \rangle$ zone axis of the catalyst-induced NWs showing basal SFs within the NWs. The inset depicts a high-resolution TEM image of the tip of a NW revealing the crystalline seed particle of the catalyst



TEM: courtesy of Igor Levin

- Higher density of extended defects in VLS NWs: **growth instabilities at the L/S interface?**
- Contamination of NWs with catalyst (indirect evidence, PL): **inside matrix or/and on sidewalls?**

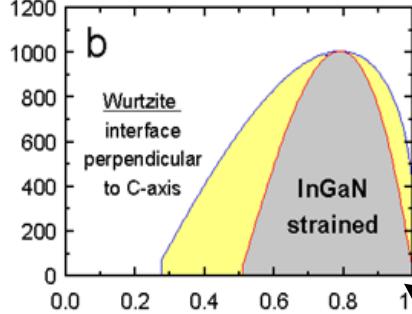
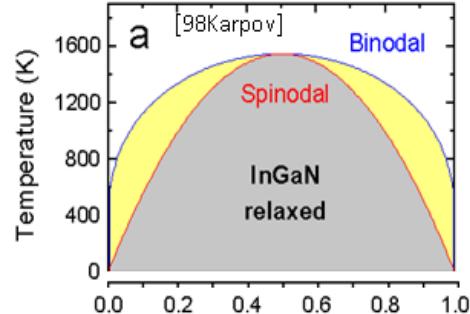


J. Ristic et al., Phys. Rev. B68, 125305 (2003)

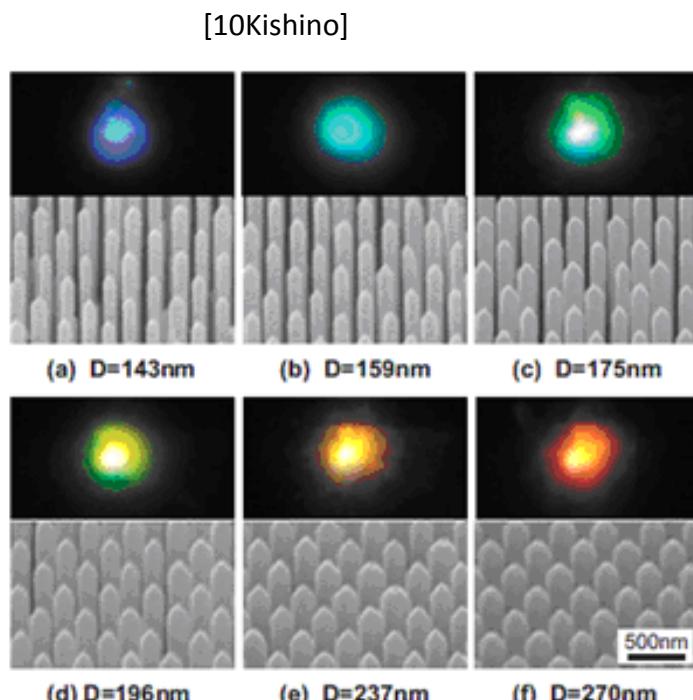
Complications:

- Heterostructure integrity
- Doping inhomogeneity
- Unified model to explain morphology?

Effect of biaxial strain during layer growth



- Higher In incorporation due to residual stress in QDs



In incorporation – function of NW diameter!

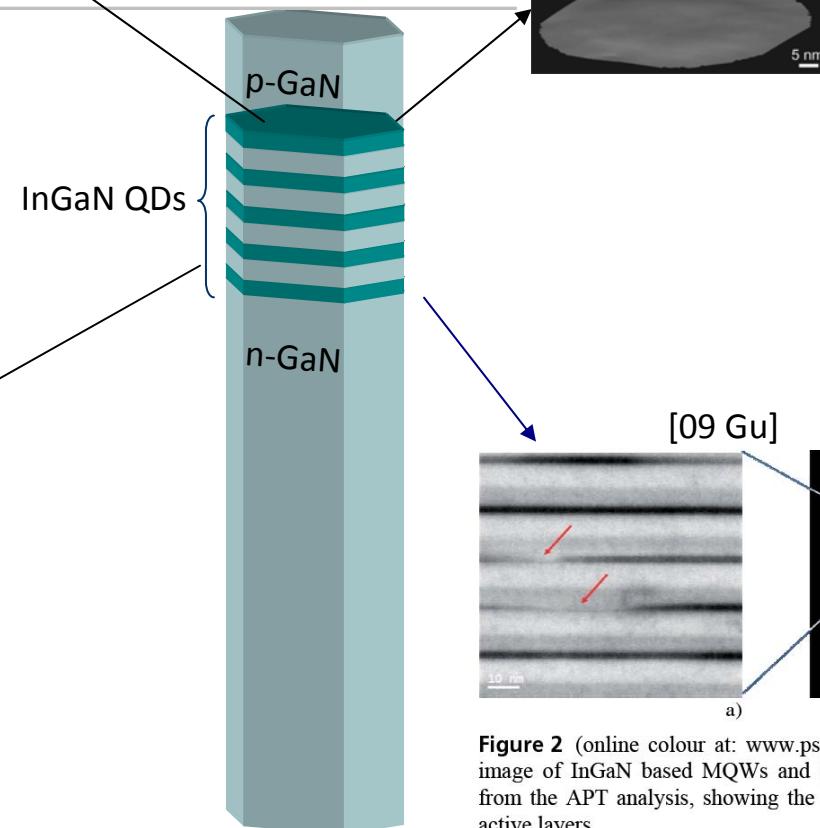


Figure 2 (online colour at: www.pss-rapid.com) (a) STEM-BF image of InGaN based MQWs and (b) 3D atom map obtained from the APT analysis, showing the discontinuity of the InGaN active layers.

- QD inhomogeneity – strain related?
- Charge localization effects in InGaN NWs

Modeling opportunities:

- VS growth:
 - understanding wetting layer formation (Stranski-Krastanov?)
 - defect formation
- VLS growth:
 - thermodynamic description of ternary systems
 - combine with VS model
 - explain NW morphologies and defects
- Core-shell and axial heterostructures:
 - strain and its relaxation – effect on morphology and composition
 - doping issues
- Surface states and their effect on opto/electronic properties